

Remarks:

Reconsideration of the application is requested.

Claims 1-14 and 21-22 remain in the application. Claim 1 has been amended.

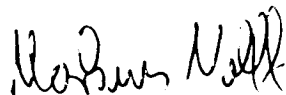
The *Notice of Non-Compliant Amendment* in the above-identified Office action has been noted and the instant amendment includes a clean version of amended claim 1. Counsel regrets the oversight.

For the reasons stated in the response dated May 2, 2003, reconsideration and allowance of claims 1-14 and 21-22 are solicited.

If an extension of time is required, petition for extension is herewith made.

Please charge any fees which might be due with respect to Sections 1.16 and 1.17 to the Deposit Account of Lerner and Greenberg, P.A., No. 12-1099.

Respectfully submitted,



For Applicants

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May 14, 2003

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Version with markings to show changes made:

Claim 1 (amended). A method of producing an electrode configuration, which comprises the following steps:

forming a first conductive layer of a material which is substantially unetchable by chemical dry-etching;

forming a second conductive layer on the first conductive layer from a material which is etchable by chemical dry-etching;

structuring the second conductive layer to form a structured second layer; and

chemical-physical dry etching the first conductive layer while using the second structured layer as a mask.